



PATENT

Attorney Docket No.: SAM-0483

Customer No.: 29344

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Jae-eun Park, et al.

Examiner: Not Yet Assigned

Serial No.:

10/782,094

Group Art Unit: 2813

Filing Date:

February 19, 2004

Title:

METHOD FOR FORMING SILICON DIOXIDE FILM USING SILOXANE

CERTIFICATE OF MAILING UNDER 37 C.F.R.§ 1.8

I hereby certify that this correspondence is being deposited with the United States Post Office as First Class Mail on the date indicated below in an envelope addressed to Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Vanessa Marakas

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

TRANSMITTAL LETTER

Sir:

Enclosed herewith for filing in the above-identified patent application please find the following listed items:

- Supplemental Information Disclosure Statement; 1.
- Forms PTO-1449 and copies of cited references AB-AF and AL-AR; and 2.
- Return Postcard. 3.

In connection with the foregoing matter, please charge any additional fees which may be due, or credit any overpayment, to Deposit Account Number 50-1798. A duplicate copy of this letter is provided for this purpose.

Respectfully submitted,

Mills & Oriello

Eleven Beacon Street, Suite 605 Boston, Massachusetts 02108

Telephone: (617) 994-4900 Facsimile: (617) 742-7774 J:\SAM\0483\SuppIDS\transsuppIDS.wpd Anthony P. Onello, Jr.

Registration Number 38,572 Attorney for Applicants



PATENT

Attorney Docket No.: SAM-0483

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7-7-04 Date

Vanessa Marakas

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Sir:	This Information Disclosure Statement is submitted:						
[]	under 37 CFR 1.129(a), or (First/Second submission after Final Rejection)						
[X]	(Within three m Office	37 CFR 1.97(b), or three months of filing national application other than a CPA under §1.53(d); or within onths of date of entry of the national stage in international application; or before mailing date of first Action on the merits; or before mailing date of first Office Action after filing RCE under §1.114, wer occurs last)					
[]	whichever occurs last)						
	[]	a Statement under 37 CFR 1.97(e), as checked below, or					
	[]	the \$180.00 fee under 37 CFR 1.17(p), or (After the 37 CFR 1.97(b) time period, but before final action or notice of allowance, or other action which closes prosecution, whichever occurs first)					
[]	under 37 CFR 1.97(d) together with:						
	[]	a Statement under 37 CFR 1.97(e), as checked below, and					
	[]	the \$180.00 fee set forth in 37 CFR 1.17(p). (Filed after final action or notice of allowance, whichever occurs first, but before payment of the issue fee)					

Applicant(s): Jae-eun Park, et al.

Serial No.: 10/782,094

Statement Under 37 C.F.R. 1.97(e)

[X]	Each item of information contained in this Information Disclosure
	Statement was first cited in any communication from a foreign patent
	office in a counterpart foreign application not more than three months
	prior to the filing of this Information Disclosure Statement.

[] No item of information contained in this Information Disclosure Statement was cited in a communication from a foreign patent office in a counterpart foreign application or, to the knowledge of the undersigned, after making reasonable inquiry, was known to any individual designated in 37 CFR 1.56(c) more than three months prior to the filing of this Information Disclosure Statement.

Enclosed herewith is form PTO-1449:

[X]	Copie	pies of cited references are enclosed.						
[]	Serial	Copies of cited references are enclosed except those entered in prior application, U.S. Serial No, and references that are not required to be submitted under 37 CFR 1.98.						
[]	The listed references were cited in a counterpart foreign application.							
Conci	se Expl	anation Requirement (non-English references):						
[X]	The "concise explanation" requirement under 36 CFR 1.98(a)(3)(i) for references AL, A and AP is satisfied by:							
	[]	the explanation provided on the attached sheet.						
	[]	the explanation provided in the Specification.						
	[X]	submission of the enclosed Search Report in related European application 03253968.6.						
	[X]	abstract.						

It is requested the information disclosed herein be made of record in this application.

* *	` ,	Jae-eun Park, <i>et al</i> . 10/782,094					
Metho	d of pay	yment:					
[]	Enclos	sed is a check in the amount of	· .				
[]	Please	charge Deposit Account of 50-1	798 in the amount of				
[]	Two duplicate copies of this Statement are enclosed.						
[X]	[X] Please charge any deficiency in fees and credit any overpayment to Deposit Acc No. 50-1798.						
	•		Respectfully submitted,				
			Anthony P. Onello, Jr. Registration Number 38,572				
	Serial Metho [] [] [X] Date: Mills	Serial No.: Method of pay [] Enclos [] Please [] Two d [X] Please No. 50	Method of payment: [] Enclosed is a check in the amount of [] Please charge Deposit Account of 50-1 [] Two duplicate copies of this Statement [X] Please charge any deficiency in fees and No. 50-1798.				

Boston, Massachusetts 02108 Telephone: (617) 994-4900 Facsimile: (617) 742-7774 J:\SAM\0483\SuppIDS\suppIDSform.wpd Attorney for Applicants

TPE	150									
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TRADEM	INFORMATION DISCLOSURE CITATION IN AN APPLICATION				Applicant Jae-eur	ı Park, <i>et</i>		702,071		
	(Use several sheets if necessary)					19/04	Group Art Unit	2813		
				U	S. Patent Doc	uments			1	
	EXAMINER INITIALS		DOCUMENT NUMBER	DATE	NAME		CLASS	SUBCLASS	FILING I IF APPRO	
		AA								
		AB	5,470,800	11-28-95	Muroyan	na	437	238	03-26-93	
		AC	6,037,275	03-14-00	Wu, et a	l.	438	780	7-98	
		AD	6,270,572	08-07-01	Kim, et a	ıl.	117	93	08-09	-99
		AE	-2002/0001974	01-03-02	Chan		438	785	06-20	-01
ĺ		AF	6,391,803	05-21-02	Kim, et a	ıl.	438	787	06-20-01	
		AG								
		AH								
		AI			i.					
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		AK								
	FOREIGN PATENT DOCUMENTS									
			DOCUMENT NUMBER	DATE	COUNTR	Y	CLASS	SUBCLASS	Transla YES	ation NO
		AL	06132276	05-13-94	Japan		H01L	21/312		х
		AM	1 096 042	05-02-01	Europe	;	C30B	25/02		
		AN	1 003 210	05-24-00	Europe	:	H01L	21/316		
		AO	10189582	07-21-98	Japan		H01L	21/316		X
		AP	2001002990	01-09-01	Japan		C09D	183/04	-	X
		AQ	1 139 399	10-04-01	Europe	· :	H01L	21/306		
	OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.							, <i>Etc</i> .)		
	Klaus, J.W., et al., "Atomic layer controlled growth of SiO ₂ films using binary reaction sequence chemistry," American Institute of Physics, 1997, Pages 1092-1094							ence		
		AS						·		

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy with next communication to applicant.

DATE CONSIDERED

EXAMINER

 \mathbf{AT}